

Agenda Thinface Management Meeting

Date: 18.10.2017
Place: BAM, Berlin
Address:

Bundesanstalt für Materialforschung und –prüfung (BAM)
Abteilung 6: „Materialschutz und Oberflächentechnik“

Unter den Eichen 87
12205 Berlin
www.bam.de

Program:

10.00-12.30 PCAM Meeting
12.30-13.30 Lunch at BAM (selfpaid)
13.30-15.00 Thinface / MONET (a new ITN)

15.00-17.00 BAM Tour

17.00- Continuation MONET if necessary

Thinface Meeting

13.30 Welcome
1. Preparation of the final Report
2. Outcome of the project
3. Pros and Cons (experiences)
4. Sustainability (alumni) / Future activities
5. New network: MONET and other suggestions

We're invited by Professor Heinz Sturm and he offers us a tour around the institution, therefore a little more information:

Meeting place is



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BAM is a senior scientific and technical Federal institute with responsibility to the Federal Ministry for Economic Affairs and Energy. It tests, researches and advises to protect people, the environment and material goods.

We will visit the Department of material protection and surface technology.

BAM is responsible for the

- further development of safety in technology and chemistry
- implementation and evaluation of physical and chemical tests of materials and facilities, including the preparation of reference processes and reference materials
- promotion of knowledge and technology transfer within the BAM's areas of work
- cooperation in the development of statutory regulations, for example concerning the setting of safety standards and limits
- advice to the Federal Government, industry, and national and international organisations in the fields of material technology and chemistry.

BAM is the successor organisation to the Staatliches Materialprüfungsamt [National Materials Testing Office], founded in 1871, and the Chemisch-Technische Reichsanstalt [Chemical-Technical State Institute], founded in 1920.